NOTES:

1. SUBSTRATE:

FUSED SILICA

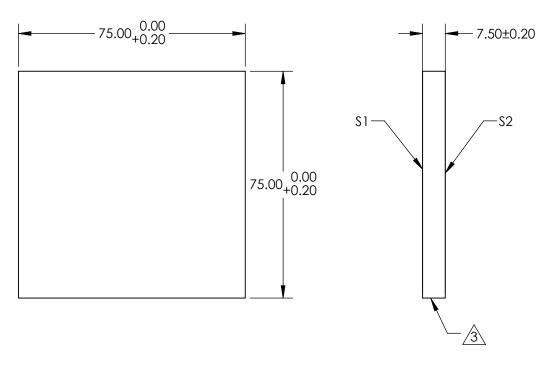
2. COATING (APPLY ACROSS CLEAR APERTURE)

\$1:DIELECTRIC MIRROR (750-1100nm) R(AVG) >98% @ 750 - 1100nm @ 0 - 45° AOI R(AVG) >99% @ 750 - 1100nm @0° AOI

S2: NONE

3. FINE GRIND SURFACE (ADD INK NOTE AS NEEDED)

4. ROHS COMPLIANT



FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

SHAPE	\$1 PLANO	S2 PLANO				Edmund Optics ®	
CLEAR APERTURE (%) SURFACE QUALITY	90 20 - 10	N/A COMMERCIAL POLISH	THIRD ANGLE PROJECTION		TITLE	75 x 75mm, 750 - 1100nm Broadband λ/10 Mirror	
SURFACE FLATNESS	λ/10	N/A				-	
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	ALL DIMS IN	mm	DWG NO		SHEET 23 OF 24